

A new route to prepare supported nickel phosphide/silica–alumina hydrotreating catalysts from amorphous alloys

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Abstract

Supported nickel phosphides were prepared by treating an amorphous Ni–B alloy on silica–alumina support with phosphine (15 vol.% PH₃/H₂) at relatively low temperature. The amorphous Ni–B/SiO₂–Al₂O₃ precursors were synthesized by silver-induced electroless plating. The amorphous precursors and catalysts were characterized by X-ray diffraction, high-resolution transmission electron microscopy, selected area electron diffraction, BET surface area and inductively coupled plasma measurements. The transmission electron micrographs of the Ni₂P/SiO₂–Al₂O₃ particles with their size ranging from 60 to 80 nm showed that they were homogeneously dispersed over the SiO₂–Al₂O₃ support. The as-prepared catalysts exhibited an excellent catalytic activity in the hydrodesulfurization (HDS) of dibenzothiophene.

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1. Introduction

The need to produce a cleaner environment has resulted in a global tightening in the allowed sulfur content of fuels. Many countries have issued new legislations to lower the allowed content in diesel fuel from the current 500–15 ppmW, and in gasoline from 300 to 30 ppmW. Therefore, hydrodesulfurization (HDS) and hydrodenitrogenation (HDN) of low-quality petroleum feedstock become increasingly important. For this reason, considerable efforts have been made being expended over the past decade to develop high-performance HDS catalysts. Many researchers modified the classic alumina-supported Mo or W sulfide catalysts promoted with Ni or Co, or investigated new active phases such as metal carbides and nitrides [1–8]. Transition-metal phosphides as a new class of hydrotreating catalysts have also attracted considerable attention. Many groups have investigated the hydrotreating of petroleum feedstocks using transition-metal phosphides, and found that these catalysts showed high activity and selectivity in HDS [9–13]. In particular, Ni₂P was found to be the most active phase among these phosphides, although other phosphides such as MoP and WP showed high HDS activities as

well. Traditional supported metal phosphides were prepared by the temperature programmed reduction (TPR) method, by which the metal salt was heated together with ammonium phosphate in hydrogen. The method is simple and easy to operate. However, it requires high temperature and easily produces impurities. Other methods, such as the solvothermal method [14], the thermal decomposition of metal–phosphine complexes [15], and the thermal decomposition of single-source molecular precursors [16], have been reported in the past years. All these methods are very useful and important, but are unsuitable for the synthesis of supported metal phosphide catalysts. Therefore, it is significant to develop an easy and effective synthesis method for preparing supported metal phosphides at low temperatures.

In the past decade, amorphous alloys have gained increasing attention as novel catalytic materials [17–20], for their unique combination of small particle size and short-range ordering as well as long-range disordered structure. Our group has carried out extensive researches in this area [21–23]. Apart from their good catalytic performance, amorphous alloys can be easily transformed into the corresponding nanocrystalline materials (NC) under proper treatment conditions, due to the metastable structure of the nanoscaled amorphous alloys [24,25]. In recent years, the amorphous-to-NC process has been thoroughly investigated and successfully applied to obtain NC materials in

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various systems [26–32]. In terms of this characteristic of amorphous alloys, in this paper, we report on a new route to preparing Ni₂P/SiO₂–Al₂O₃ by treating amorphous Ni–B alloys with PH₃ at low temperature. In general, it is very important to control the dispersion of the active sites on the surface. Therefore, we choose the metal-induced electroless-plating route from the numerous methods for synthesizing amorphous alloy precursors, so that amorphous particles can be first anchored to and homogeneously dispersed over the support, which favours to producing a supported Ni₂P catalyst with high dispersion. Recently, Yang et al. have reported a method to prepare Ni₂P/SiO₂ by treating Ni/SiO₂ with PH₃ [33]. The preparation conditions were mild. However, they only used silica as the carrier. Here, we use industrial amorphous silica–alumina (silica 88 wt.%, alumina 12 wt.%) as a carrier because it provides much higher surface area and large pores enough to assure a high dispersion of the active phase on the support. To avoid a strong interaction induced by a high reduction temperature between nickel phosphide and the surface of the support, we use the electroless-plating method and first plate a Ni-based alloy on the support at 35 °C, and subsequently treat the amorphous alloy at a relatively low temperature.

2. Experimental

2.1. Preparation of amorphous alloy precursors

Commercially available solvents and reagents were used without further purification. The Ni–B/SiO₂–Al₂O₃ amorphous alloy precursors were prepared by the silver-induced electroless-plating method [23]. Silver nitrate (0.02 g) was dissolved in distilled water (47.5 mL), silica–alumina (10.0 g) was added to, and then the solution was stirred for 3.0 h. The resulting Ag/SiO₂–Al₂O₃ was filtered, washed with a small volume of distilled water and dried under vacuum at 120 °C for 3 h. The Ni–B plating solution consisted of nickel sulfate (7.9 g/L), ammonium hydroxide (15 g/L), and potassium borohydride (5.5 g/L). The required amount of Ag/SiO₂–Al₂O₃ was added to 100 mL of the plating solution. The resulting solution was heated to 35 °C and vigorously stirred. After 0.5 h, the black Ni–B/Ag/SiO₂–Al₂O₃ precipitate was collected, washed with a small volume of distilled water and anhydrous ethanol, and then dried under vacuum at 80 °C for 3 h.

2.2. Catalyst preparation

The resulting Ni–B/Ag/SiO₂–Al₂O₃ was heated at 150–350 °C in a sealed quartz tube in a furnace, and 15 vol.% PH₃/H₂ (synthesized using the procedure given in [34]) carried by

hydrogen was passed through the quartz tube at a rate of 5 mL min^{−1}. The reaction was maintained for 2 h, and then the sample was cooled to room temperature in flowing argon. Finally, the samples were passivated in a flow of 1 vol.% O₂/N₂ (10 mL/min). The passivated samples were handled in air.

2.3. Amorphous precursor and catalyst characterization

The particle size and surface morphology of the samples were determined using a JEOL-2010 high-resolution transmission electron microscope (HRTEM) equipped with a selected area electron diffraction (SAED) system. The X-ray diffraction (XRD) patterns of the samples were recorded on a Rigaku-D/MAX 2500 X-ray powder diffractometer with a Cu K α radiation source ($\lambda = 1.5418 \text{ \AA}$). A scan rate of 0.05° s^{−1} was used to record the patterns in the 2 θ range 20–80°. The elemental content of the samples was determined using the inductively coupled plasma (ICP-AES, 9000(N + M)) method. The BET surface areas (S_{BET}) were measured by N₂ adsorption at −196 °C using an automatic surface area and pore size analyzer (Autosorb-1-MP 1530VP). S_{BET} measurements were performed using the five-point BET method.

2.4. Activity test

The HDS of dibenzothiophene was carried out in a flowing fixed-bed reactor using a feed consisting of a decalin solution of DBT (0.5 wt.%). The conditions of the HDS reaction were 320 °C, 3.0 MPa, WHSV = 9 h^{−1}, and H₂ flow rate 90 ml min^{−1}. 1.0 mL (0.6 g) of Ni₂P/SiO₂–Al₂O₃ catalyst diluted with quartz sands to 5.0 mL was reduced by heating from room temperature to a certain temperature in H₂ (200 mL min^{−1}), maintaining the sample at that temperature for 2 h, before changing the temperature to the desired reaction temperature. Liquid samples were collected every hour and analyzed by a gas chromatography with a flame ionization detector (FID) and a capillary column (OV101). The DBT conversion was used as a measure of the HDS activity.

3. Results and discussion

3.1. Characterization of the amorphous precursors and catalysts

All supported catalysts were prepared with the same loading of nickel (Table 1). Fig. 1 shows the XRD patterns of the amorphous samples and the SiO₂–Al₂O₃ support. The XRD pattern of the support shows that the SiO₂–Al₂O₃ powder is amorphous, because of the lack of sharp peaks. The XRD

Table 1
Compositions and specific areas of the Ni–B/Ag/SiO₂–Al₂O₃ precursors and Ni₂P/Ag/SiO₂–Al₂O₃ catalysts

Sample	Metal loading (wt.%)	$S_{\text{BET}}/\text{m}^2 \text{ g}^{-1}$	Composition (atomic ratio)	Content of B (wt.%)	Content of Ag (wt.%)
Ag/SiO ₂ –Al ₂ O ₃	–	–	–	–	0.16
Ni–B/SiO ₂ –Al ₂ O ₃	10.93 (Ni)	221	Ni _{75.2} B _{24.8}	0.62	0.16
Ni ₂ P/SiO ₂ –Al ₂ O ₃	10.93 (Ni)	142	Ni _{2.06} P	0.59	0.15

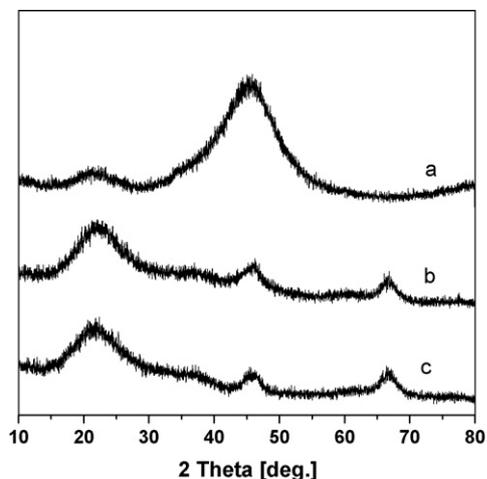


Fig. 1. XRD patterns of (a) amorphous Ni-B, (b) amorphous Ni-B/SiO₂-Al₂O₃, and (c) SiO₂-Al₂O₃.

patterns of the Ni-B alloy and Ni-B/SiO₂-Al₂O₃ catalyst are presented in Fig. 1a and b. The broad and dispersive peak at $2\theta = 45^\circ$ is caused by the amorphous structure of the Ni-B particles and is characteristic to amorphous alloy (Fig. 1a). The small profile around $2\theta = 22^\circ$ is attributed to amorphous boron oxide, which is inevitably formed when the reduction is carried out in aqueous solution [35]. The Ni-B/SiO₂-Al₂O₃ sample does not show obvious differences from the SiO₂-Al₂O₃ carrier (Fig. 1b) due to the very good dispersion of the Ni-B particles on the support. In addition, the strong peak of the support around $2\theta = 45^\circ$ and the weak diffraction signal of amorphous Ni-B alloy cannot be neglected.

The XRD patterns of the samples treated by PH₃ at 150–350 °C are shown in Fig. 2b–f. The samples obtained at 150, 200,

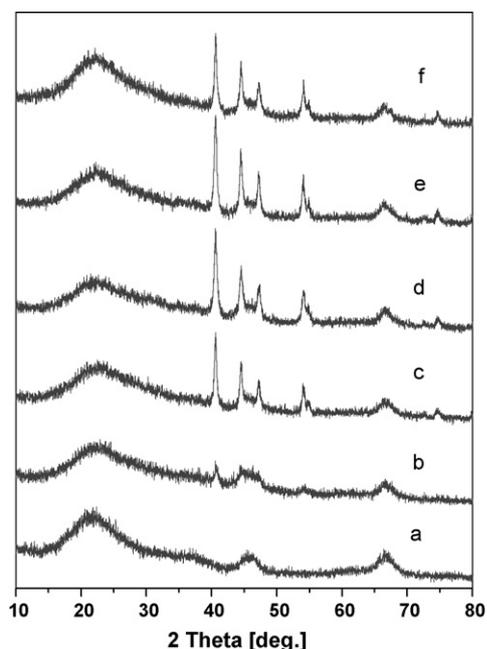


Fig. 2. XRD patterns of (a) SiO₂-Al₂O₃, (b) Ni₂P-150, (c) Ni₂P-200, (d) Ni₂P-250, (e) Ni₂P-300, and (f) Ni₂P-350.

250, 300 and 350 °C are denoted as Ni₂P-150, Ni₂P-200, Ni₂P-250, Ni₂P-300, and Ni₂P-350, respectively. The sharp diffraction lines (around $2\theta = 40.8, 44.6, \text{ and } 47.3^\circ$) of the five samples are assigned to the hexagonal cell of the Ni₂P phase. The XRD pattern of Ni₂P is similar to the reference pattern taken from the JCPDS powder diffraction file (Card 65-1989) [36], as well as the XRD patterns of Ni₂P reported recently by others [9–13]. It can be observed that there are no crystalline impurities other than the phase of Ni₂P in Fig. 2b–f. However, whether the amorphous structure has disappeared with increasing reaction temperature cannot be concluded from the XRD patterns of the samples, because the $2\theta = 45^\circ$ peak of Ni-B overlaps with the peak of silica-alumina. Bulk Ni-B was only completely converted to crystalline Ni₂P at 250 °C, because the dispersive characteristic peak of the amorphous alloy at $2\theta = 45^\circ$ just disappeared until 250 °C in the XRD pattern of bulk Ni₂P (Fig. 3). Therefore, we concluded that the amorphous characteristic of the samples had not disappeared at 150 and 200 °C, and that all the diffraction lines were due to crystalline Ni₂P and the SiO₂-Al₂O₃ support when the reaction temperature was further increased to 250, 300 and 350 °C (Fig. 2d–f). However, the intensity of the Ni₂P peaks first increased gradually and then decreased from 250 to 350 °C. The reason is the better crystallization of the Ni₂P at higher temperature. The narrower peak width also proves the point with the increasing temperature. The decreased intensity at 350 °C may be ascribed to the interaction between the Ni₂P phase and the support [37]. These experimental results demonstrate that the treatment temperature is a key factor in determining the reaction products. In addition, the traditional temperature-programmed reduction (TPR) method must break the strong P–O bond in phosphates [33]. Therefore, the route requires a high temperature. In comparison with the TPR method, we utilize the reaction of metastable and nanoscale amorphous alloys with PH₃, so that the catalysts can be prepared under mild conditions. The representative nickel phosphide catalysts were prepared at 250 °C, which guarantees that the amorphous precursors could be completely transformed.

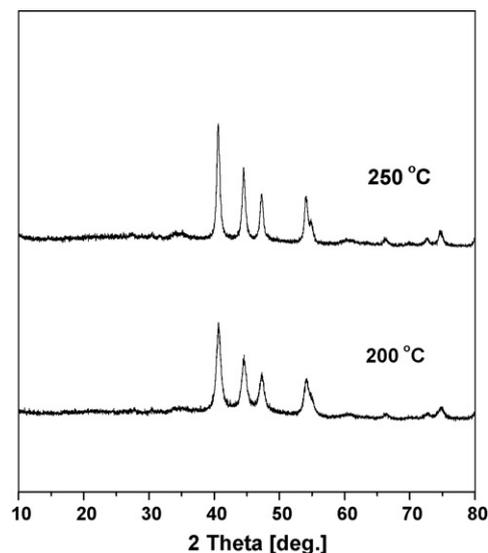


Fig. 3. XRD patterns of Ni₂P from bulk Ni-B.

The bulk compositions of the as-prepared samples determined by ICP analysis are given in Table 1. Table 1 shows that the chemical composition of supported Ni–B was $\text{Ni}_{75.2}\text{P}_{24.8}$. Table 1 also shows that the average mole ratio of nickel to phosphorus in the as-prepared supported Ni_2P samples is 2.06. In addition, as shown in Table 1, a small quantity of boron and silver still remains in the Ni_2P sample.

The TEM and HRTEM images of the as-synthesized Ni–B/ $\text{SiO}_2\text{--Al}_2\text{O}_3$ and $\text{Ni}_2\text{P-250/SiO}_2\text{--Al}_2\text{O}_3$ samples are shown in Fig. 4. Fig. 4a shows that the spherical Ni–B particles with their diameters in the range of 40–60 nm were homogeneously dispersed on the support. According to the literature [23], in the formation process of amorphous Ni–B, tiny silver clusters are first distributed randomly over the support; after several minutes, the silver clusters are coated with deposited nickel clusters due to

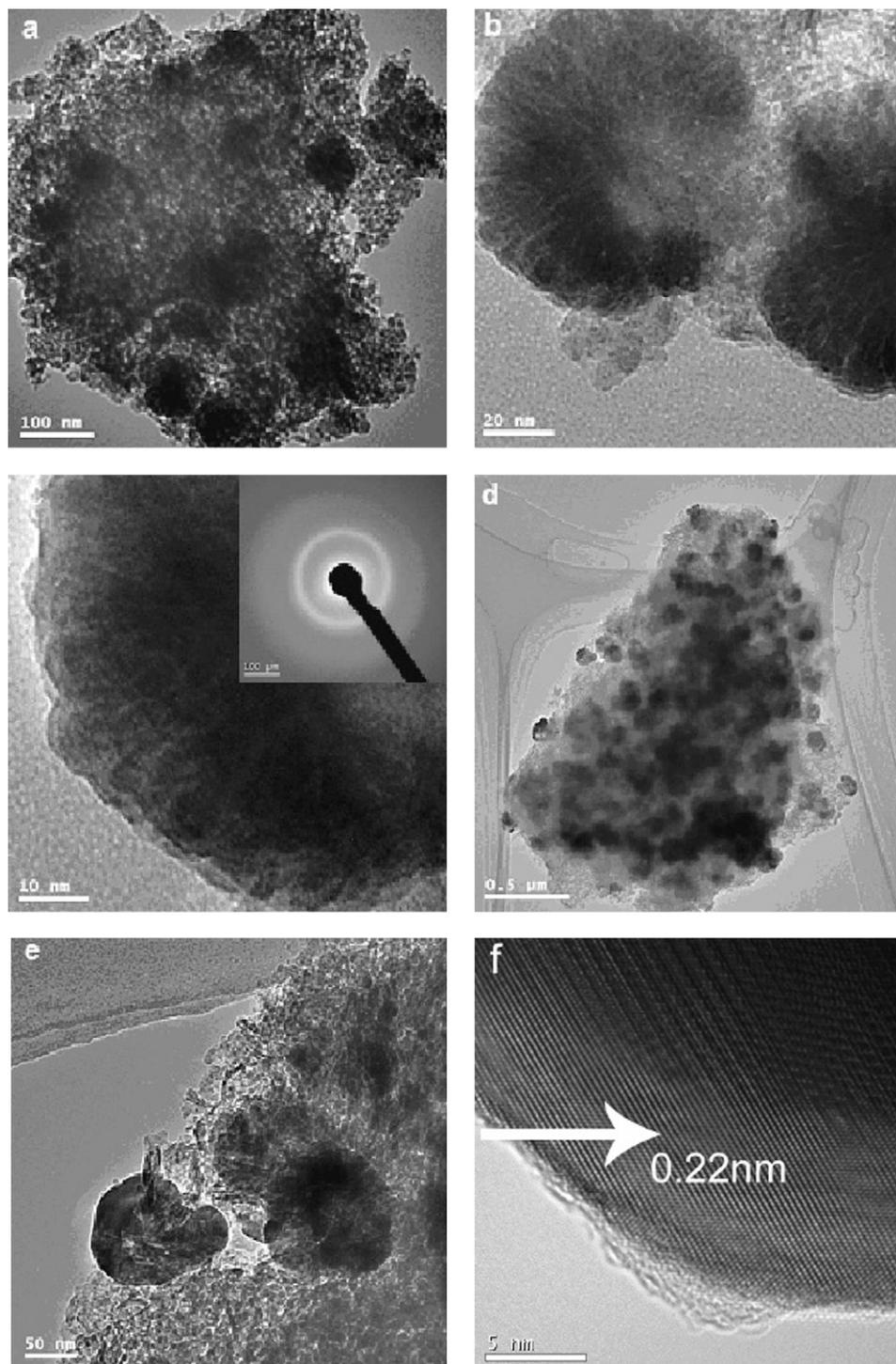


Fig. 4. TEM and HRTEM micrographs of (a) Ni–B/ $\text{SiO}_2\text{--Al}_2\text{O}_3$, (b) Ni–B/ $\text{SiO}_2\text{--Al}_2\text{O}_3$, (c) Ni–B/ $\text{SiO}_2\text{--Al}_2\text{O}_3$, (d) $\text{Ni}_2\text{P-250/SiO}_2\text{--Al}_2\text{O}_3$, (e) $\text{Ni}_2\text{P-250/SiO}_2\text{--Al}_2\text{O}_3$, and (f) $\text{Ni}_2\text{P-250/SiO}_2\text{--Al}_2\text{O}_3$.

the silver catalysis. The results clearly show that silver plays an important role in controlling the dispersion of Ni–B on the support. By carefully observing Fig. 4b, we can see that every particle contains many regular pores from the interior to the exterior surface. It is obvious that the structure is different from the solid spheres of conventional Ni–B particles [22]. The reason for forming a porous structure is mainly due to the process of preparing the supported amorphous Ni–B by the silver-catalyzed chemical plating method [23]. The porous structure can expose more metal sites on the surface so that it is easier to form Ni₂P when Ni–B was treated by PH₃. To investigate the nature of Ni–B, a Ni–B particle was magnified further (Fig. 4c). Fig. 4c clearly shows there is no visible lattice in the particle, which is characteristic to an amorphous substance. The result is consistent with the XRD pattern (Fig. 1b). In addition, a dispersive ring in the SAED further testifies that the Ni–B sample is amorphous (Fig. 4c). Figs. 4d–f shows the TEM and HRTEM images of Ni₂P-250/SiO₂-Al₂O₃. The TEM image of the Ni₂P-250/SiO₂-Al₂O₃ sample (Fig. 4d) shows that the Ni₂P particles are spherical and homogeneously dispersed over the support. The particle size is in the range of 60–80 nm (Fig. 4e). In the HRTEM image of the Ni₂P particles on the SiO₂-Al₂O₃ support (Fig. 4f), the visible lattice spacing is 0.22 nm, consistent with the d-spacing value for {1 1 1} crystallographic planes of the Ni₂P phase measured by XRD (Fig. 2d). This result further testifies that the active phase on the support is crystalline Ni₂P.

3.2. Activity measurements

The hydrotreating activity of the Ni₂P/SiO₂-Al₂O₃ catalysts was tested by the HDS of DBT. To further study the preparation of the SiO₂-Al₂O₃-supported catalysts, the effects of treatment temperature, carrier gas and reduction temperature on the HDS activity of the as-synthesized nickel phosphides were investigated. The Ni loading in all samples was 10.93 wt.% (Table 1). The specific areas are also listed in Table 1. As shown in Table 1, the specific area of Ni–B/SiO₂-Al₂O₃ is higher than that of Ni₂P/SiO₂-Al₂O₃. The decrease in the BET area is mainly caused by the pore blocking of the silica–alumina support.

Fig. 5 shows the effect of the final treatment temperature on the HDS performance of Ni₂P/SiO₂-Al₂O₃. It is obvious that

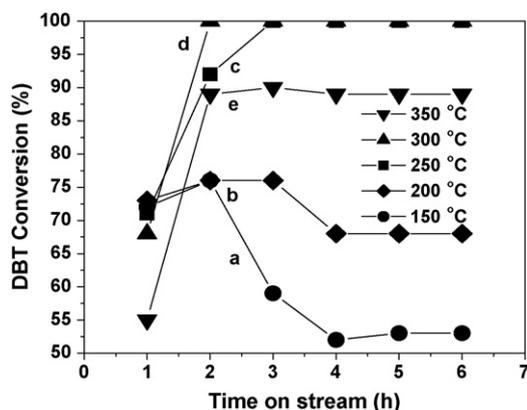


Fig. 5. Dependence of HDS activity on the final treatment temperature: (a) 150 °C, (b) 200 °C, (c) 250 °C, (d) 300 °C, and (e) 350 °C.

the active phase can be obtained above 250 °C, in agreement with the XRD analysis results. The Ni–B on the support was not completely transformed to the active Ni₂P phase at 150 and 200 °C, and the structure of crystalline Ni₂P was not well formed because the diffraction line intensity of the products is very faint at 150 and 200 °C (Fig. 2b and c), therefore the two samples exhibit a decreasing HDS activity with time on stream (Fig. 5a and b). The conversion of DBT reached 100% and the activity maintains stable when the treatment temperature was increased to 250 and 300 °C (Fig. 5c and d). It is clear that the treatment at 250 and 300 °C gave much better results than that at other temperatures. However, the conversion fell to 89% when the treatment temperature reached 350 °C (Fig. 5e). A possible reason for this is the effect of the interaction between the Ni₂P phase and the support. The interaction results in a lower content of Ni₂P, so that the HDS activity decreases. Therefore, it is suggested that the treatment at 250 or 300 °C is necessary to prepare highly active nickel phosphides.

To investigate the effect of H₂ in the preparation process, H₂ was replaced by Ar. Fig. 6 shows that the gas type has significant on the HDS activity of the catalysts, demonstrating that the gas is not only a carrier or simply removes some adsorbents from the surface, but also may affect the optimization of the structure of phosphide. Therefore, it is clear that a mixture of H₂ and PH₃ is essential to obtain high-performance nickel phosphides in our method.

Generally, the catalysts were passivated with 1 vol.% O₂/N₂ before being exposed to air to prevent a rigorous breakage on the surface. But there is still a small oxide layer on the surface of the catalysts after passivation so that the performance of the catalysts will be greatly affected. Therefore, prior to the activity evaluation, the samples were reactivated in a H₂ flow. To investigate the effect of reduction temperature, the catalysts were evaluated after being reduced at 400 or 500 °C for 3 h. The HDS activity of the catalyst reached 100% when the reduction temperature was 400 °C and the WHSV was 9 h⁻¹ (Fig. 7). Therefore, the WHSV was increased to 12 h⁻¹ for the convenience of comparison. The results are displayed in Fig. 6. It is clear that the HDS conversion at 500 °C is superior to that at 400 °C. A possible reason for this is that the oxidized crystal structure is better renewed at the higher reduction

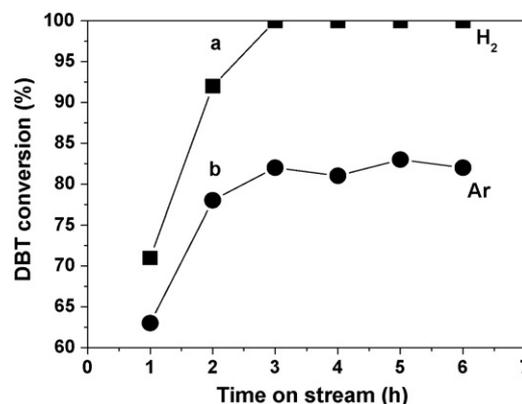


Fig. 6. Effect of flowing gas type on the HDS activity of the nickel phosphides: (a) H₂ and (b) Ar.

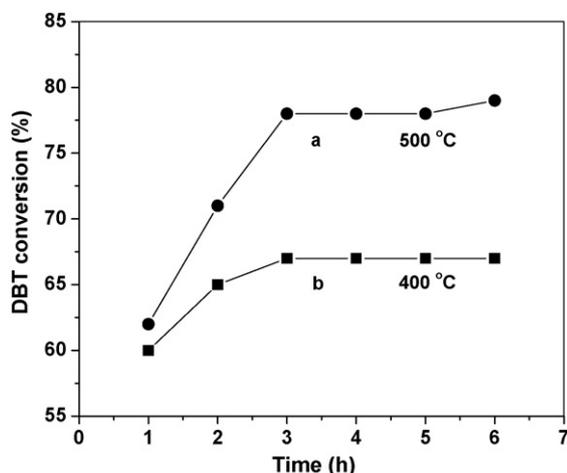


Fig. 7. Effect of reduction temperature on the HDS activity of the nickel phosphides: (a) 400 °C and (b) 500 °C.

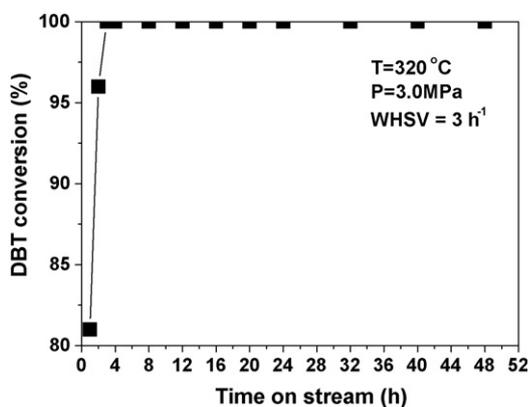


Fig. 8. Effect of reaction time on the HDS activity of the nickel phosphides.

temperature so that much more active sites of the catalysts can be exposed, leading to an improvement in the HDS performance. Fig. 8 shows the HDS results of the catalyst during 48 h. The HDS activity becomes stable within 3 h, and the HDS conversion reaches 100%. The catalyst does not suffer from deactivation during the experiment and the conversion of the final hour is still as high as 100%.

4. Conclusions

Our results demonstrate that silica–alumina-supported nickel phosphide ($\text{Ni}_2\text{P}/\text{SiO}_2\text{--Al}_2\text{O}_3$) was successfully prepared by the novel route proposed in the present investigation. By using metastable and nanoscale amorphous Ni–B precursors, the preparation process does not require any complex operation and high temperature. In addition, the silver-induced electroless plating was applied to synthesize the nickel phosphide catalysts, which generated an active phase that was well dispersed on the surface of the support, so that the resulting catalyst showed a high catalytic activity. The amorphous precursors can be fully phosphided above 250 °C. The as-prepared silica–alumina-supported nickel phosphide exhibited a good activity for the HDS of DBT.

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